

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	97915	(cvd chemical adj vapor adj deposit\$4) and plasma	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/07 17:10
L2	18794	1 and (atomic monolayer nanometer near3 (layer film) nano adj layer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/07 17:15
L3	8724	2 not (@rlad>"20010910" @ad>"20010910")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/03/07 17:13
L4	846	3 and (repeat\$3 repetition) near5 step	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/07 17:14
L6	63	4 and (more thicker greater) near3 (atomic monolayer) with (form\$3 formation deposit\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/07 17:19
L7	63	6 and (more thicker greater) near3 (atomic monolayer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/07 17:19